

MRS Elects Officers, Councillors for 2000

Members of the Materials Research Society have elected two officers and three councillors to join the 2000 Council, which consists of the Executive Committee and 15 councillors. The annual election ended October 15, 1999.

2000 MRS Officers

President

Harry A. Atwater (2000)
California Institute of Technology

Immediate Past President

Ronald Gibala (2000)
University of Michigan

Vice President (President-Elect)

*Marty Green (2000)
Bell Laboratories, Lucent Technologies

Secretary

*Chuang Chuang Tsai (2001)
Applied Komatsu Technology

Treasurer

Merrilea J. Mayo (2000)
Pennsylvania State University

2000 MRS Councillors

Michael J. Aziz (2000)
Harvard University

*Orlando Auciello (2002)
Argonne National Laboratory

Katayun Barmak (2000)
Carnegie Mellon University

John W. Cahn (2001)
National Institute of Standards
and Technology

Anthony K. Cheetham (2001)
University of California—Santa Barbara

David J. Eaglesham (2000)
Bell Laboratories, Lucent Technologies

A. Lindsay Greer (2001)
Cambridge University

Alexander H. King (2000)
Purdue University

Karen Maex (2000)
IMEC, Belgium

Stephen J. Pennycook (2001)
Oak Ridge National Laboratory

Caroline A. Ross (2001)
Massachusetts Institute of Technology

Alan I. Taub (2000)
Ford Motor Company

Rudolf M. Tromp (2001)
IBM T.J. Watson Research Center

*R. Stanley Williams (2002)
Hewlett-Packard Laboratories

*Anne M. Mayes (2002)
Massachusetts Institute of Technology

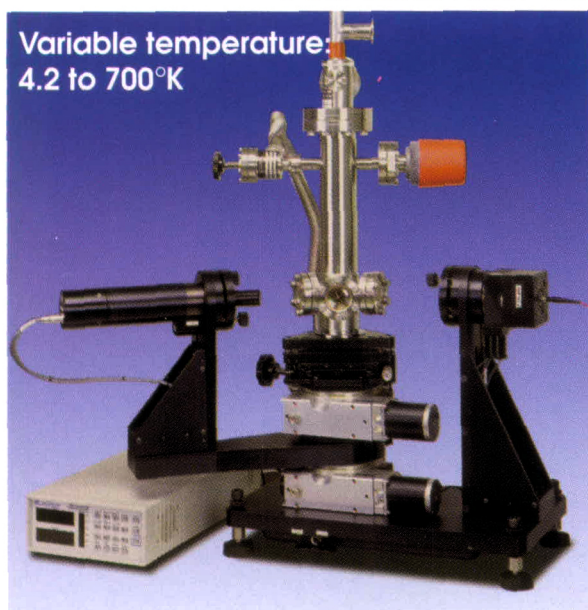
(Terms of office expire at the end of the years indicated in parentheses.)

*Newly elected.

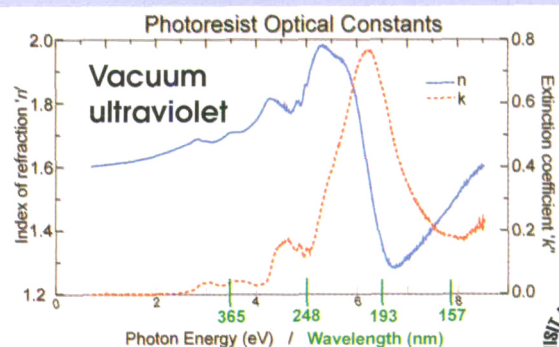
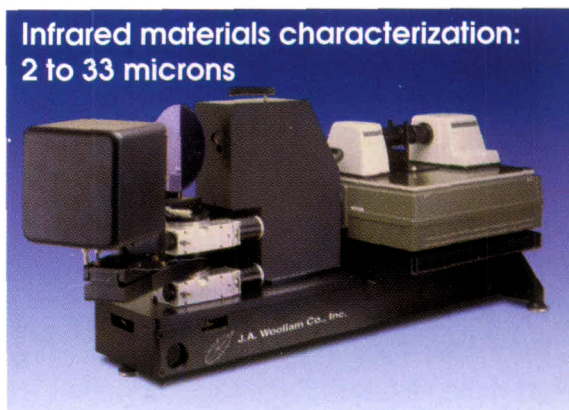
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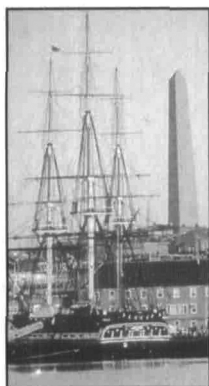


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The MRS Exhibit, held in conjunction with the 1999 MRS Fall Meeting, will feature more than 225 international exhibitors from all sectors of the materials science and engineering marketplace. Learn the latest techniques, advances and future of materials science and engineering directly from the manufacturers, suppliers and developers. Or browse the new releases, publications and journals from the various publishers. The exhibit will closely parallel the nature of the technical symposia and, as always, the program has been arranged to allow meeting participants ample opportunity to visit the exhibit.

The 1999 MRS Fall Exhibit—everything you need... all under one roof!

Exhibit Hours

Tuesday, November 30	11:30 am - 6:00 pm
Wednesday, December 1	9:00 am - 6:00 pm
Thursday, December 2	9:00 am - 2:00 pm

Partial List of Fall Exhibitors

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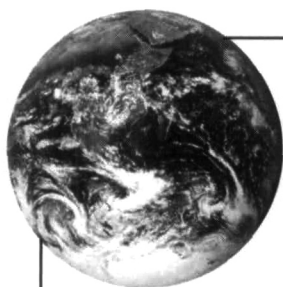
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*Please visit us at the Exhibit, November 30–December 2, during the 1999 MRS Fall Meeting in Boston.



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